

# The AlbaNova Nano Fabrication Facility

Nano technology for basic research  
and small commercial enterprises

Director: Prof. David Haviland

# Nano-Lab Philosophy

- Nanometer scale patterning and metrology
- Broad spectrum of user research, stimulate new ideas
- Graduate students post docs are users, help maintain
- Small technical staff, minimal administration
- Flexible environment for basic research
  - Direct writing techniques, small series production
- Wide variety of materials
- Small format for machines

# Used by many institutions in Stockholm

*KTH MAP ,Kista*

*KTH S3,campus*

*Companies:*  
Cobolt, Lingvita,  
Spintronix  
KIMAB

*KTH Applied Phys., Albanova  
Nanophysics  
Bio Med. X-ray  
Laser Physics*

*KTH –other  
Surface Chemistry  
Biotechnology*

*SU Physics, Albanova  
Exp. Cond. Mater Physics  
Quantum Optics*

# Funding:

Phase 1: 9 M SEK KA Wallenberg

Phase 2: 10 M SEK KA Wallenberg

Phase 3: 7 M + 3M SEK KA Wallenberg +VR

( + ca 4.5 M SEK: VR, G. Gustafsson, KTH Start-up, Misc. )

5 Laminar flow benches

2 Photo  
Lithography

Wet bench, hood

Surface Profilometer

E-beam lithography

Scanning Probe Microscope

Scanning Electron Microscope

Focused Ion Beam System

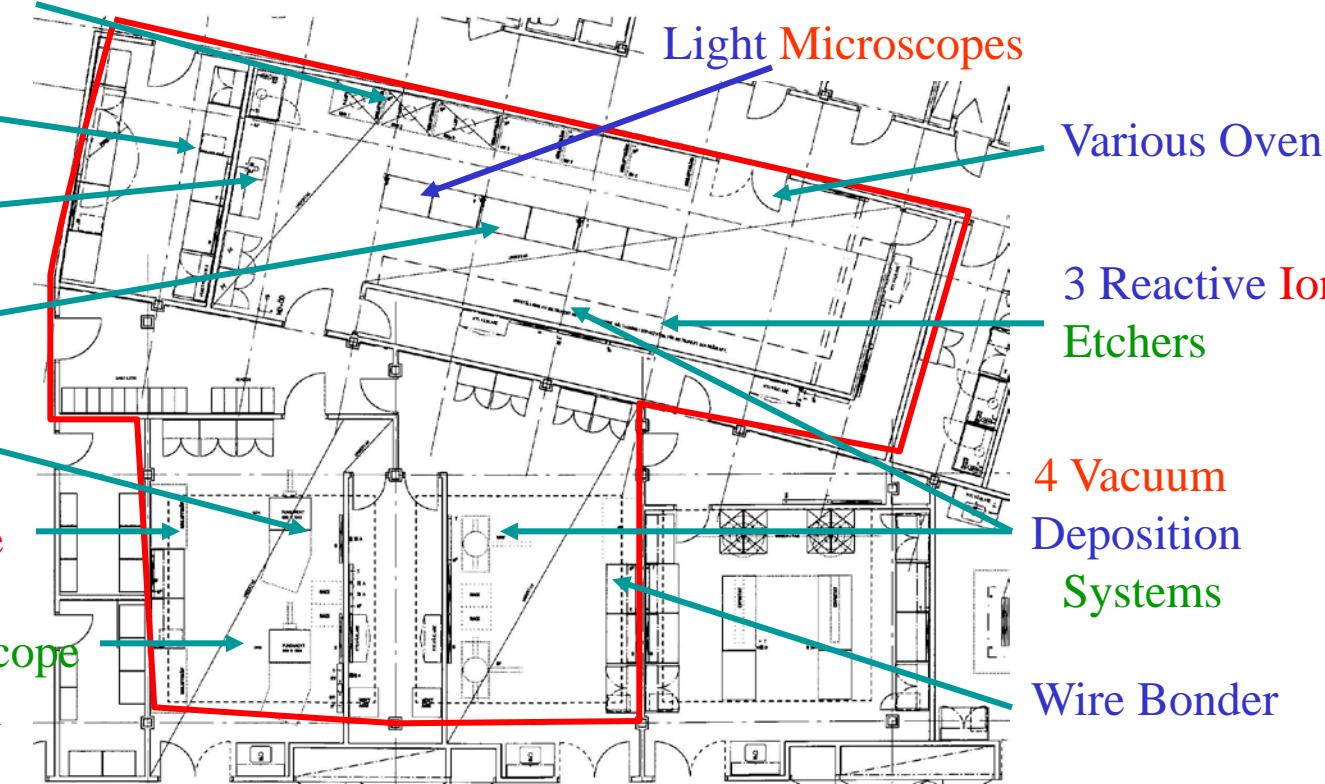
Light Microscopes

Various Ovens

3 Reactive Ion  
Etchers

4 Vacuum  
Deposition  
Systems

Wire Bonder



345 m<sup>2</sup> total - 285 m<sup>2</sup>, clean room 500 - 2000 part. / ft<sup>3</sup>  
Lab coat , hair net, latex gloves, clean benches



## Equipment

## E-beam lithography

Booking FBMS upgrade

## Dual beam system

Booking

## SPM/AFM/STM

Booking

## Profilometer

RIE, Ar, O<sub>2</sub>RIE, BC<sub>l</sub><sub>3</sub>, Cl<sub>2</sub>

## Mask aligner

Booking

## Projection mask aligner

## Multi target Sputtering

## System

## UHV E-gun sputtering

## HV E-gun deposition

Booking

## UHV E-gun / Ion gun

## Bonder

## Laminar flow benches

## Optical microscope, DIC, DF

## Opt. micr. 5 Mpix camera

## Opt. micr., yellow lab

## Fluor. micr. w. cooled CCD

## Stereoscope

## Resist spinner

## Resist spinner #2

## Hotplate

## Hotplate #2

## Clean water

## Carbon coater

## Evacuated oven

## Ultrasound, vari-power

## Useful links

## Usage and Safety

## Activity Report (pdf)

## Resist data limited access

## Clean-room particle count

## Nano-Fab-Lab Wiki

## NanoFabLab users, phonelist

## Service and labs, phonelist

## Chemical database

- Joint KTH SU laboratory facilities, with broad user spectrum
- Nano and micro scale fabrication, imaging and metrology
- Graduate students and post docs are users
- Low overhead costs, flexible lab environment for exploratory research

KTH Applied physics and SU Physics jointly run this facility located in [AlbaNova University Center](#). There are about 30 active users from several departments at KTH and SU. If you are interested in access, contact director [Prof. David Haviland](#) or manager [Dr. Anders Liljeborg](#).

Most of the equipment has been financed by grants from the [K. A. Wallenberg Foundation](#).

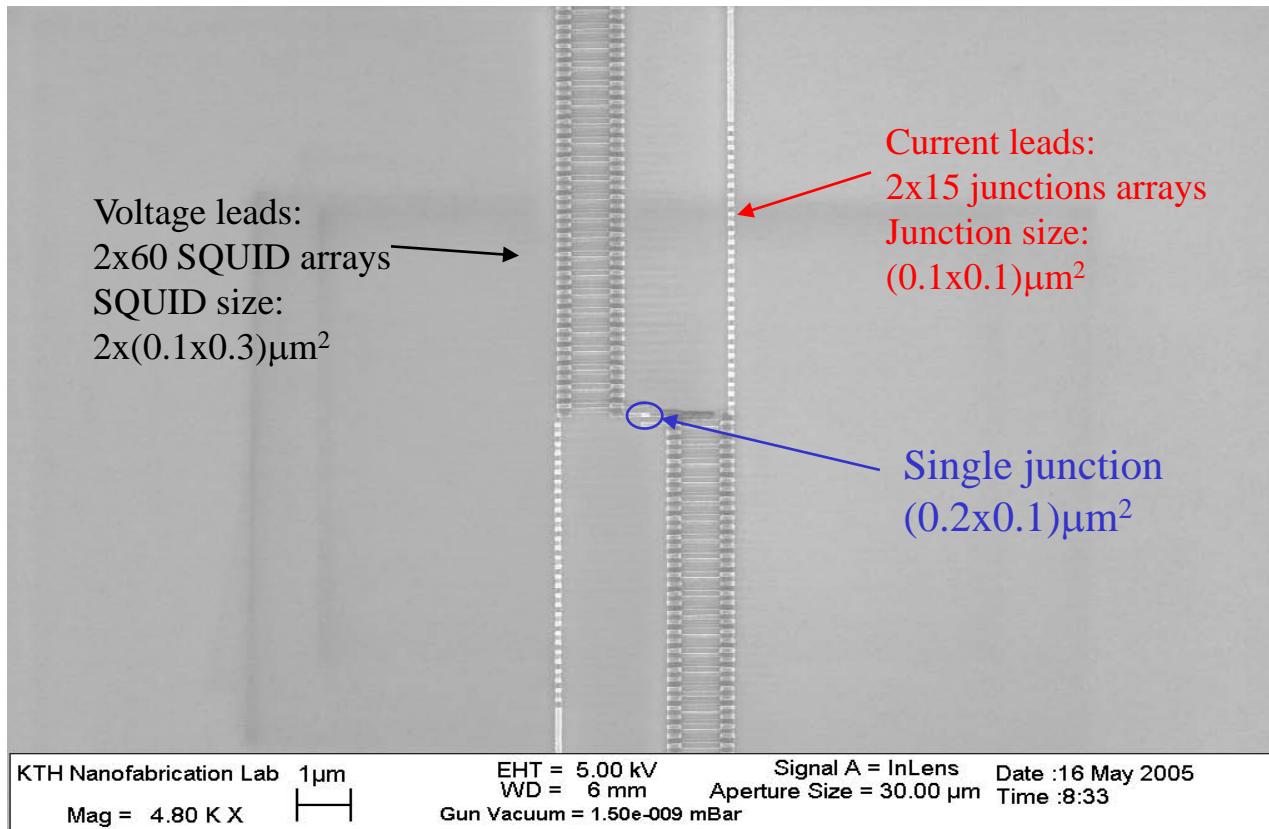


# Homepage

- Simple, Functional, not Sexy
- Practical user-oriented
- Manuals, Dos and Don'ts
- Up-to-date with problems, fixes

# Josephson Junction Arrays for Circuit QED

*David Haviland, Applied Physics, KTH*

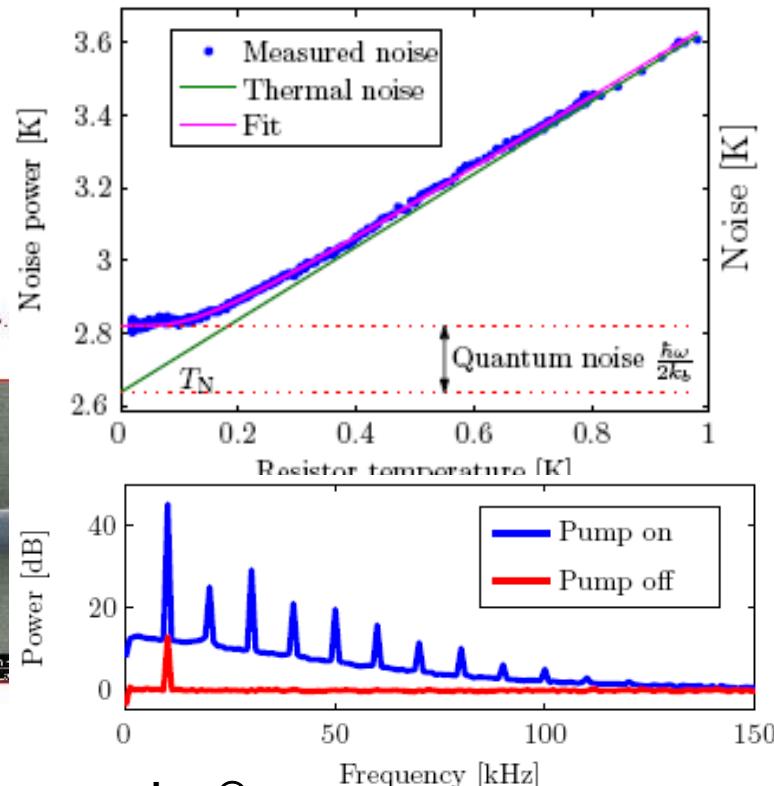
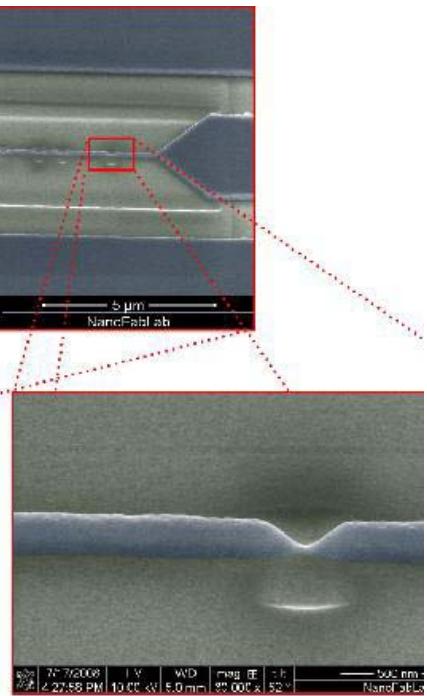
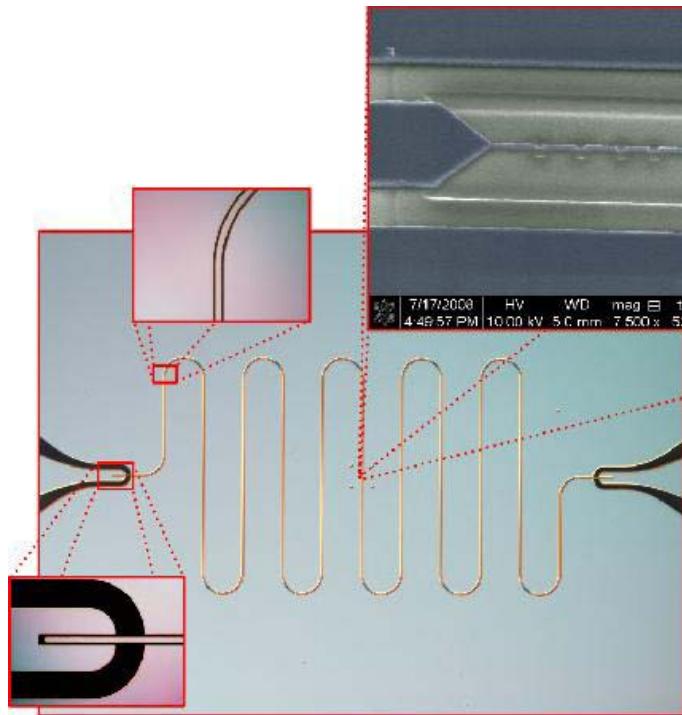


- 800 tunnel junctions in circuit
- SQUID's give tunable Josephson coupling.
- High impedance gives Coulomb blockade of superconducting condensate.

Phase-Charge Duality of a Josephson Junction in a Fluctuating Electromagnetic Environment.  
S. Corlevi, W. Guichard, F.W.J. Hekking and D. B. Haviland. Phys. Rev. Lett. **97**, 096802 (2006)

# Superconducting microresonators for Parametric amplification and quantum noise squeezing

*David Haviland, Applied Physics, KTH AlbaNova*

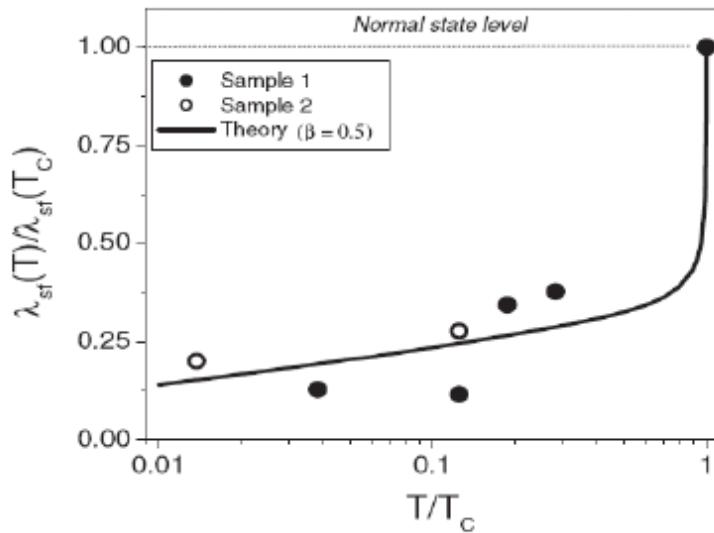
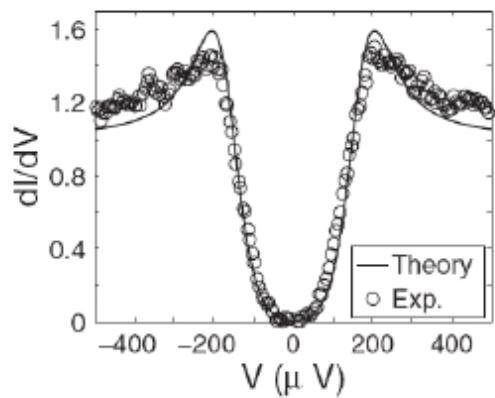
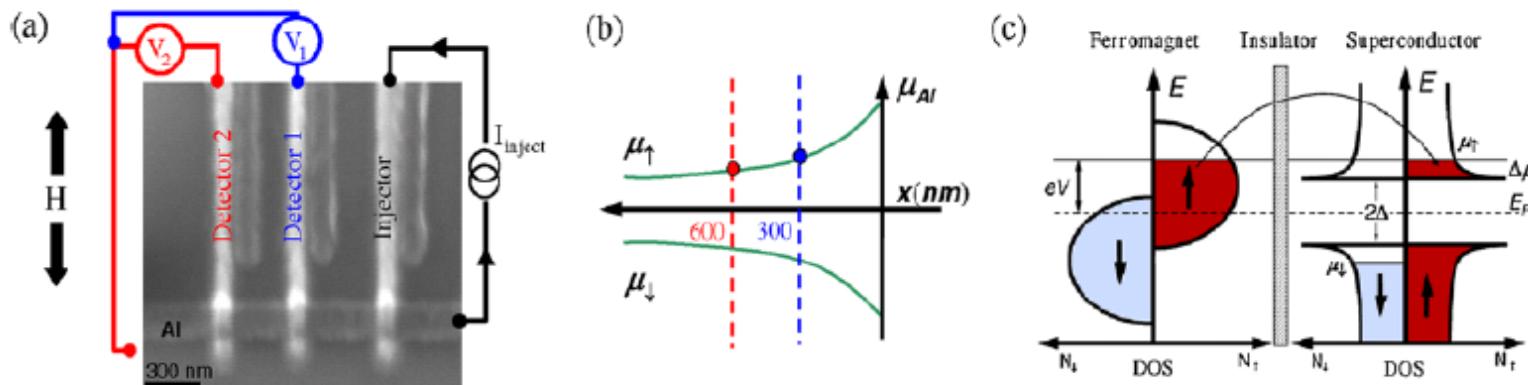


Amplifier Noise temperature 440 mK, no noise squeezing ☺

E. Tholén, A. Ergul, K. Stannigel C. Hutter and D. B. Haviland. Proc. Nobel Symp. on Quantum, Phys. Scr. 014019 (2009)

# Spin Transport in Mesoscopic Superconductors

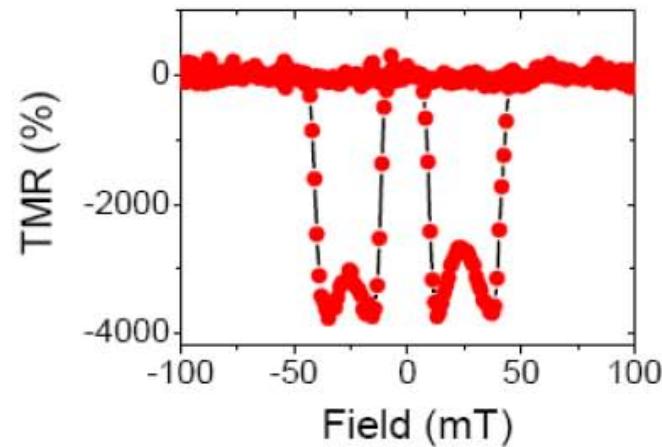
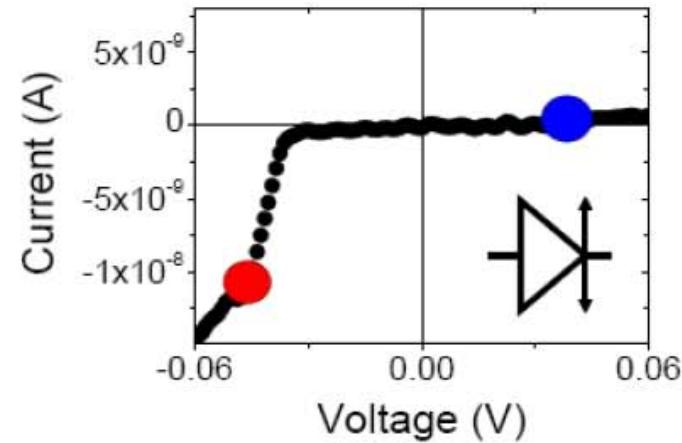
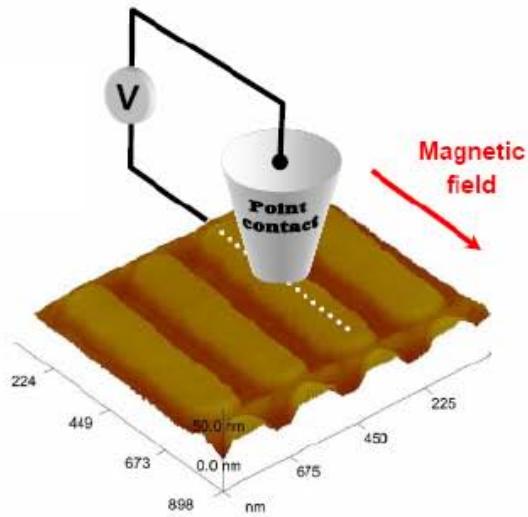
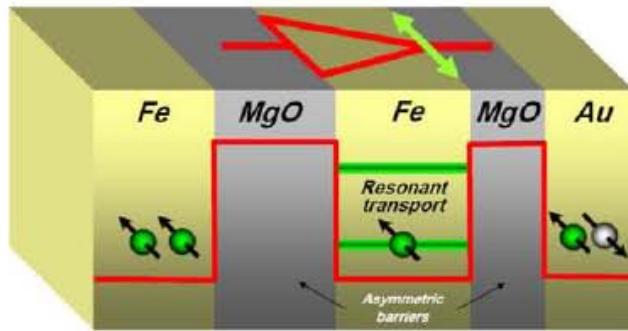
Vladislav Korenivski, Applied Physics, KTH AlbaNova



Spin injection and relaxation in a mesoscopic superconductor, N. Poli, J. P. Morten, M. Urech, A. Brataas, D. B. Haviland, V. Korenivski, Phys. Rev. Lett. 100 (2008) 136601

# Spin Diode

Vladislav Korenivski, Applied Physics, KTH Albanova

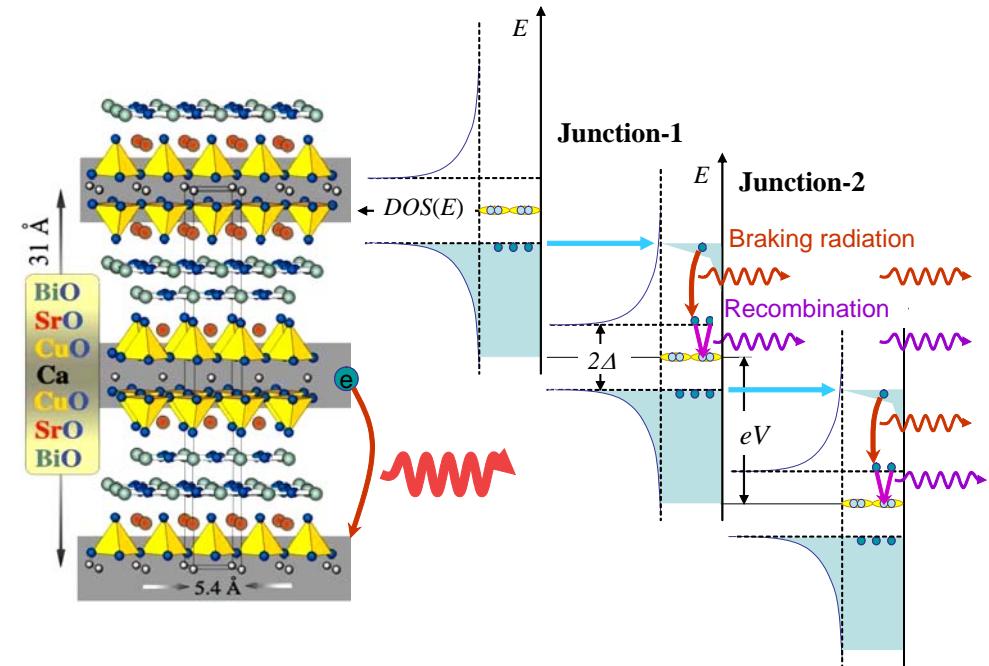
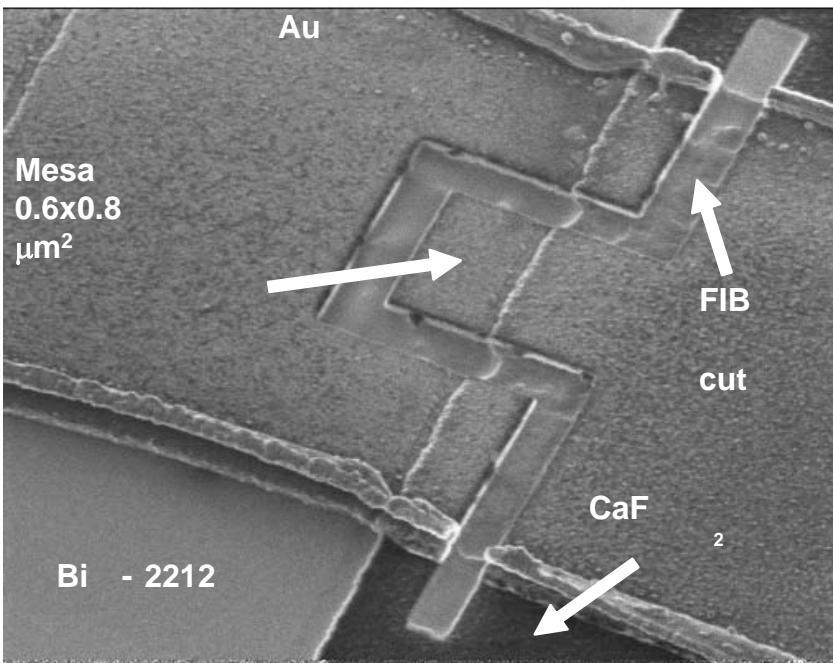


Spin Diode Based on Fe/MgO Double Tunnel Junction, A. Iovan, S. Andersson, Yu. G. Naidyuk, A. Vedyayev, B. Dieny, V. Korenivski, Nano Letters 8 (2008) 805

# Intrinsic tunneling in high T<sub>c</sub> superconductors and natural atomic superlattices

Vladimir Krasnov, Dept. Physics, SU AlbaNova

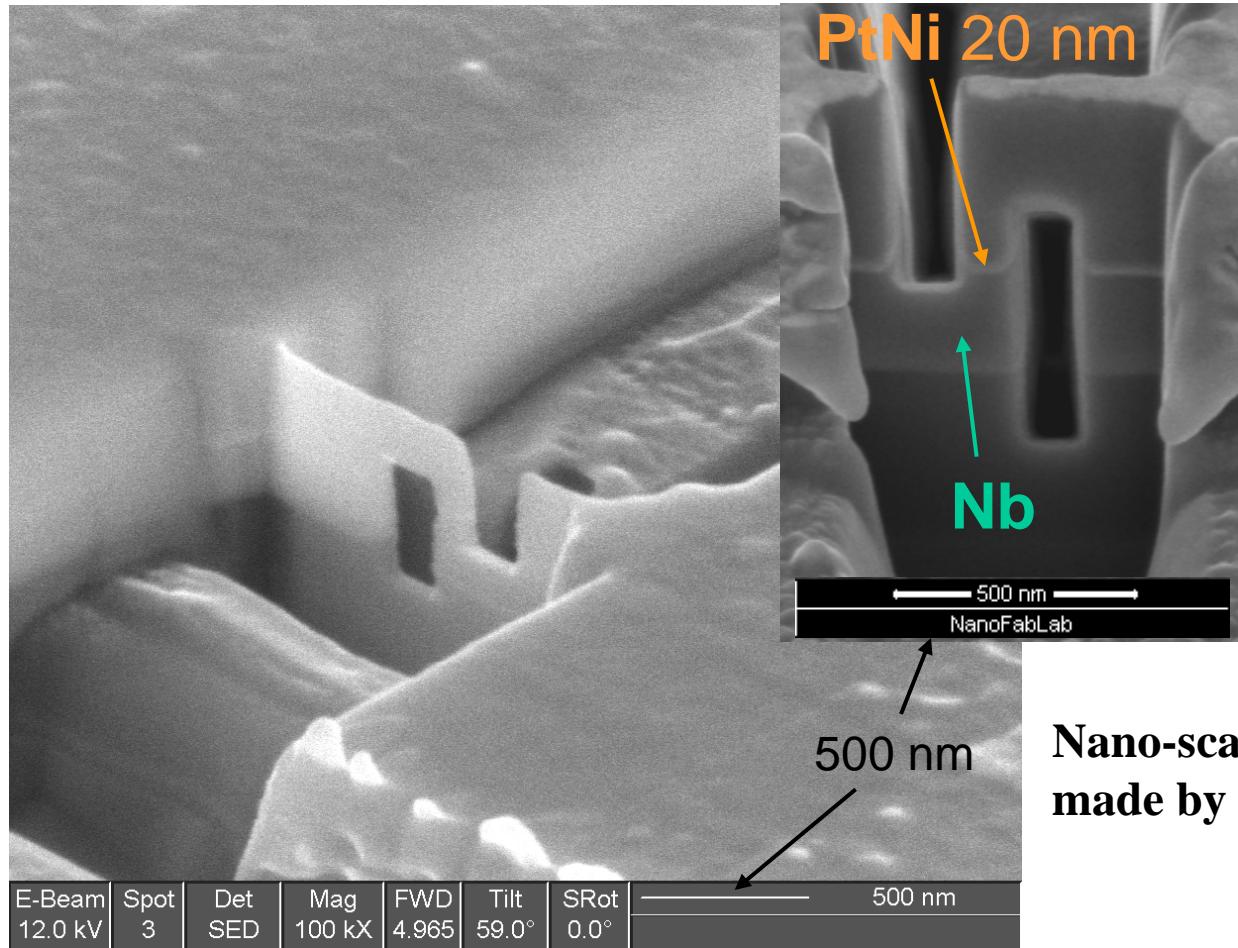
Quantum cascade phenomenon in  $\text{Bi}_2\text{Sr}_2\text{CaCu}_2\text{O}_8$  single crystals



V. Krasnov, Phys. Rev. Lett. 97, 257003 (2006)

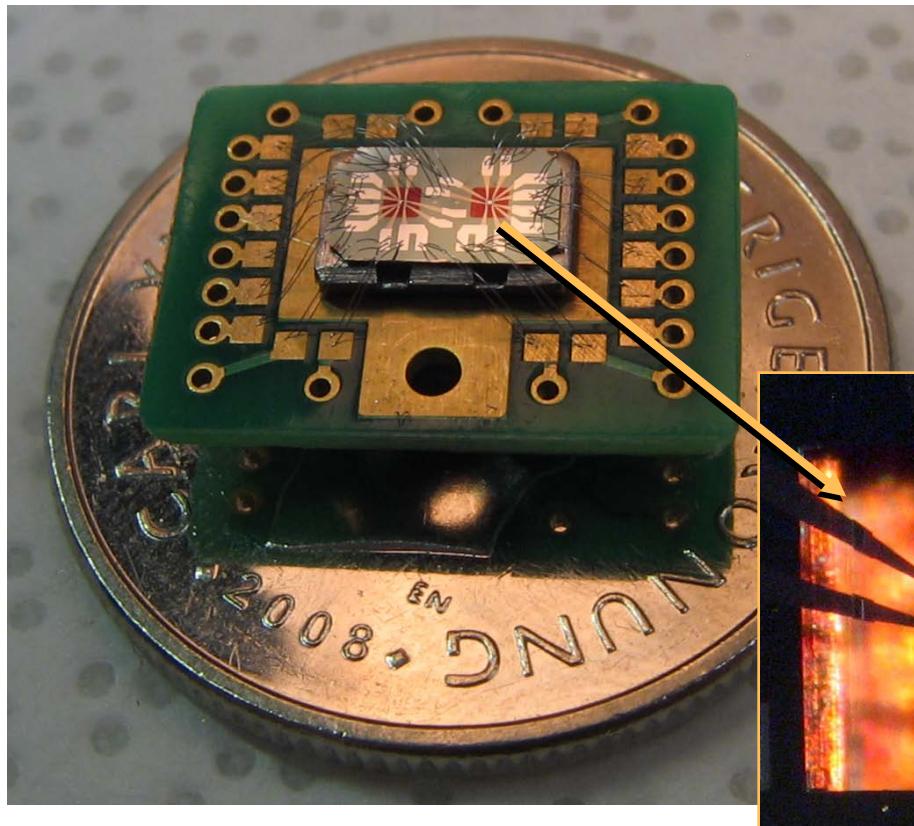
# Hybrid Superconductor-Ferromagnet Components for Quantum Electronics

*Vladimir Krasnov, Dept. Physics, SU AlbaNova*



# Nanocalorimetry for thin films and mg to sub-ug crystals

Andreas Rydh, Department of Physics, Stockholm University



Specific heat capacity

- AC, relaxation methods
- Differential setup
- Sub-K to 400 K
- Temp. scan 100 K within cell
- Resolution: 1 in  $10^4$  to  $10^5$

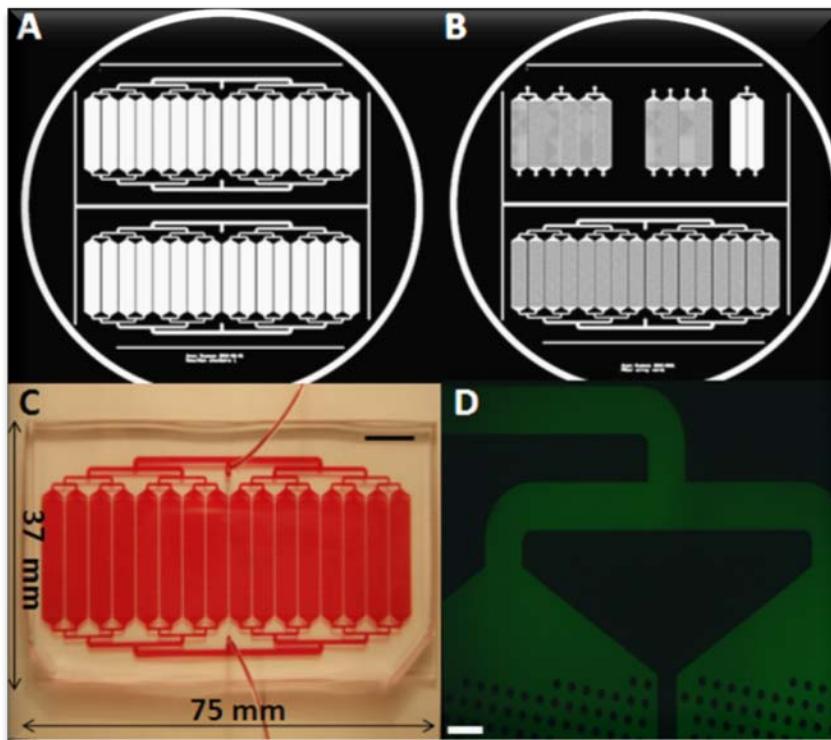
$\text{Si}_3\text{N}_4$ : 150 nm  
area  $1 \times 1 \text{ mm}^2$   
30-50 nm layers

Membrane-based calorimetry for studies of sub-microgram samples

S. Tagliati, A. Rydh, R. Xie et al., Journal of Physics: Conference Series **150**, 052256 (2009).

# Microfluidic devices for blood diagnostics

*Aman Russom, Applied Physics, KTH*



(A-B) Mask designs, and (C-D) PDMS based microfluidic devices functionalized with antibodies. Scale: 250 $\mu$ m

- Microfluidic based cell capturing assay
- Parallel-plate immunoassay devices
- Application: capturing of white blood cells and bacteria from blood

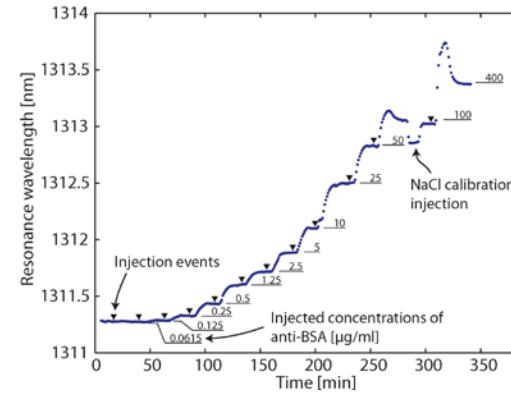
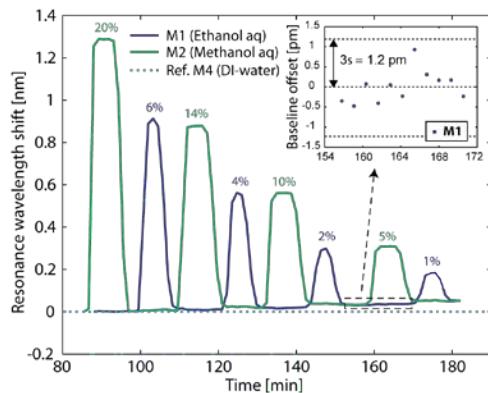
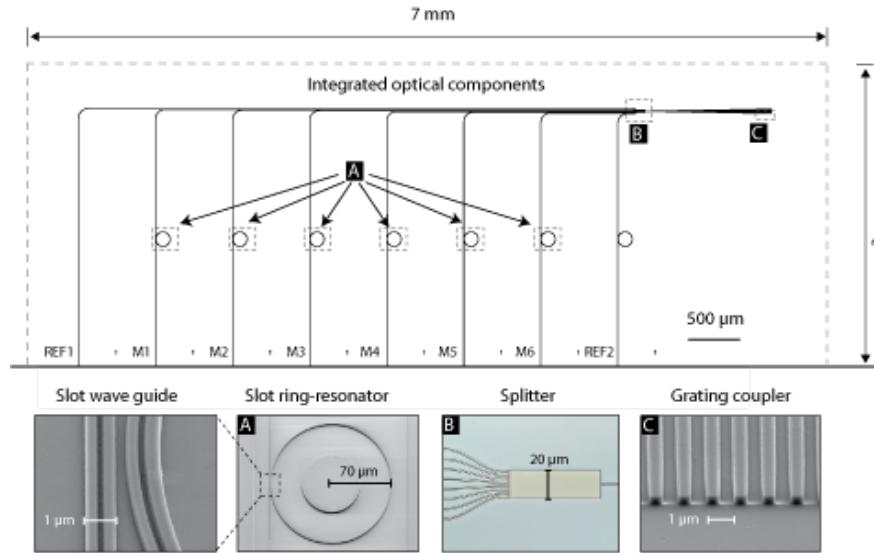
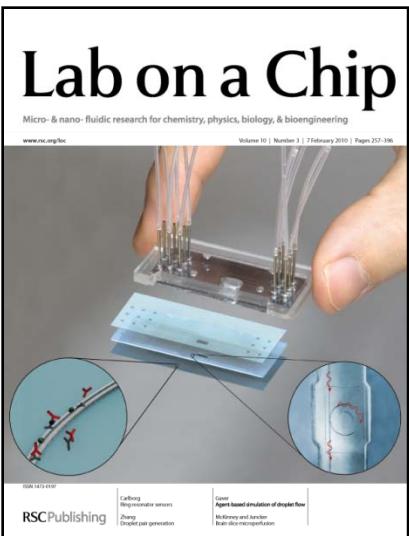
Dean-coupled inertial focusing for ultra-high throughput particle filtration.

S. Ardabili, J. Gantelius, J. Kowalewski, H. Brismar and A. Russom.

Micro Total Analysis Systems, Groningen Netherlands, Oct 2010. (accepted)

# Optical Ring Resonator Biosensor Arrays

Goran Stemme, Microsystem Technology Lab, KTH



"A packaged optical slot-waveguide ring resonator sensor array for multiplex label-free assays in labs-on-chips". Carlborg, Gylfason, Sohlström, Stemme, W. Van der Wijngaart et al., *Lab on a Chip*, **10**, 281, (2010)

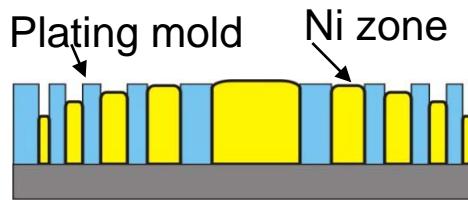
- Sensor array for multiplex **label-free biosensing**
- Concurrent **real-time measurement** of up to 6 biomarkers
- Integrated microfluidic sample handling
- Surface mass density detection limit **0.9 pg/mm<sup>2</sup>**

# X-ray diffractive optics

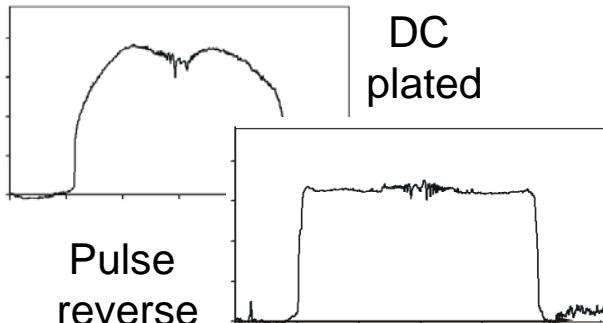
Hans Hertz, Applied Phys. KTH AlbaNova

M. Bertilsson et al., RSI (2007); Holmberg et al, JVST (2006); Lindblom et al, JVST (2006)

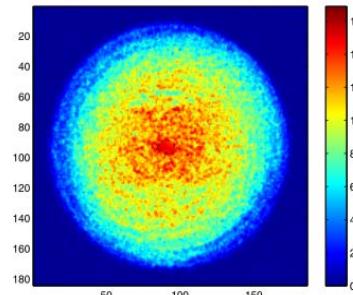
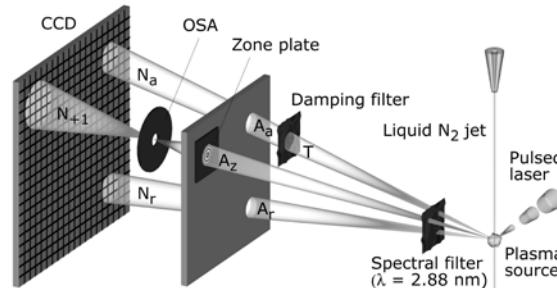
## Electro-plating uniformity



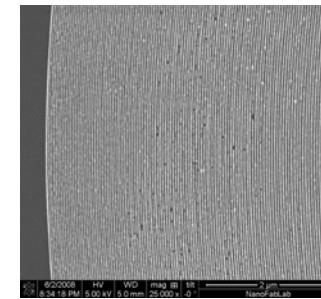
## Pulse plating



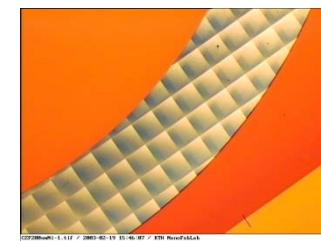
## Local diffraction efficiency measurm.



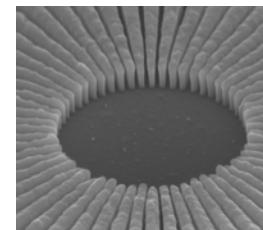
## Structures



20-25 nm Ni zone plates



5 mm diam condensers



Test patterns

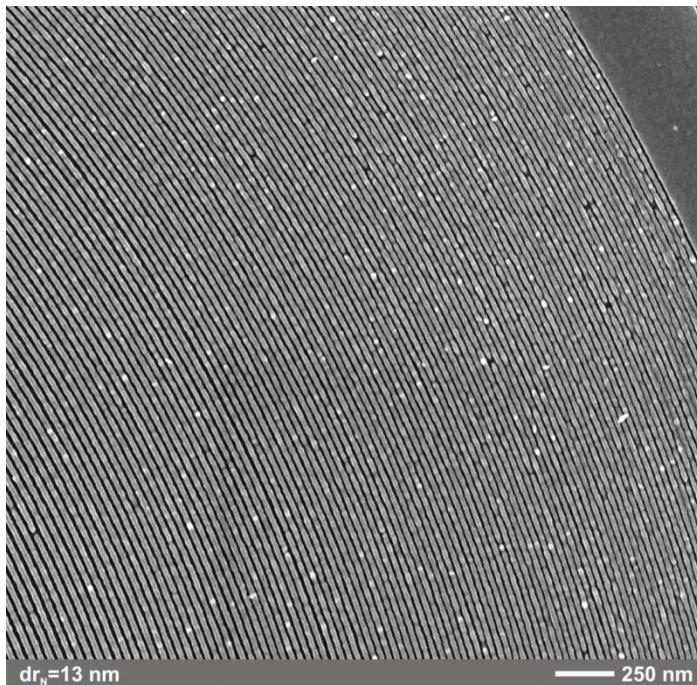


# High Resolution EBL

*Hans Hertz, Applied Phys. KTH AlbaNova*

Single-write Ni ZP

Reinspach et al., JVST B (2009)



$\varnothing = 19 \mu\text{m}$

$dr_N = 13 \text{ nm}$ ;  $h = 35 \text{ nm}$

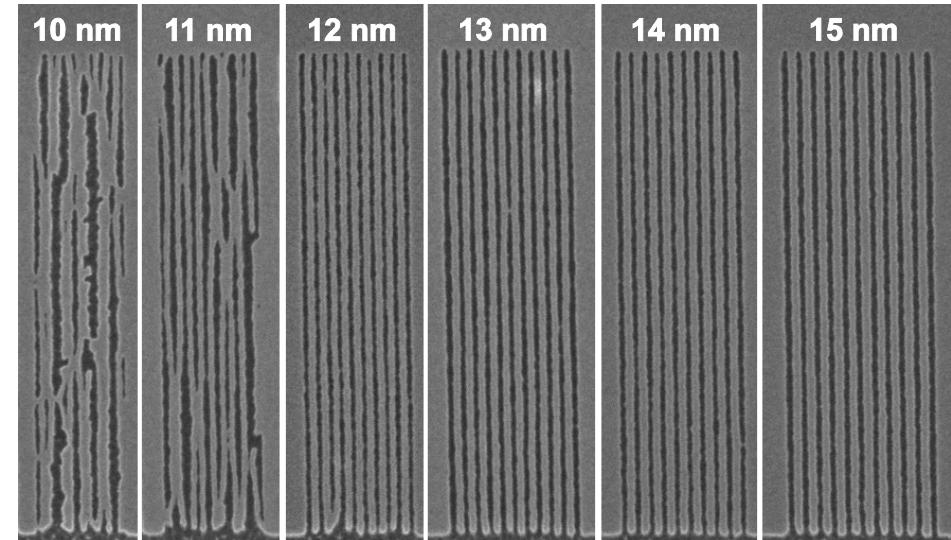
$f = 100 \mu\text{m}$  @  $\lambda = 2.48 \text{ nm}$

Excellent uniformity

Efficiency: 2.7% (15 nm/h = 55 nm zp)

Cold development: ZEP in hex acet

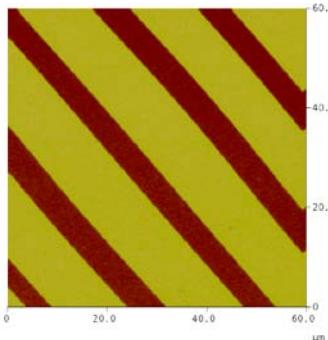
Good Mold stability



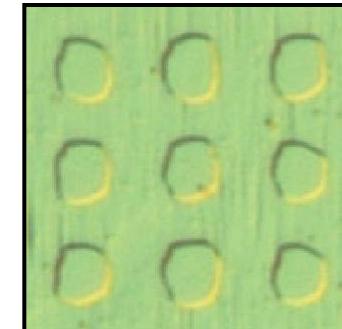
# Ferroelectric domain engineering for novel optical applications

*Fredrik Laurell, Applied Physics, KTH AlbaNova*

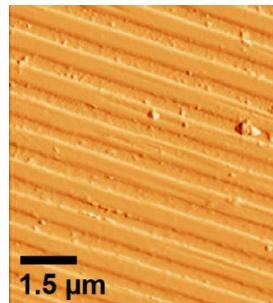
Micro- and nano-meter ferroelectric domains electrically polled 1 mm bulk ferroelectric crystal



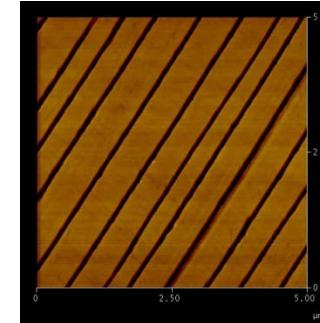
Frequency conversion  
 $\Lambda = 20 \mu\text{m}$



2D nonlinear photonic crystal  
 $\Lambda = 6.09 \mu\text{m} \times 6 \mu\text{m}$



Electrically addressable Bragg reflectors  
 $\Lambda = 800 \text{ nm}$



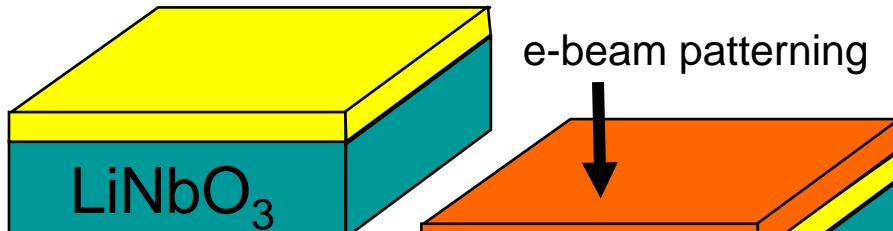
Self-assembled nanostructures  
 $\Lambda = 500 \text{ nm}$

C.Canalias et al. Appl. Phys. Lett. 86, 181105 (2005)

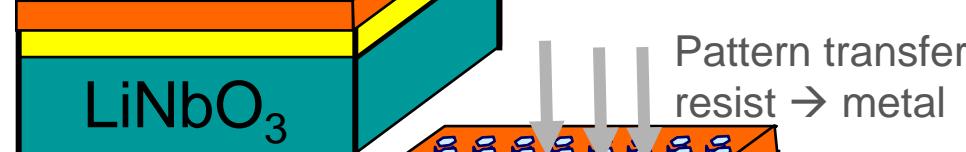
# Nonlinear photonic crystals

*Fredrik Laurell, Applied Physics, KTH*

Metal layer deposition

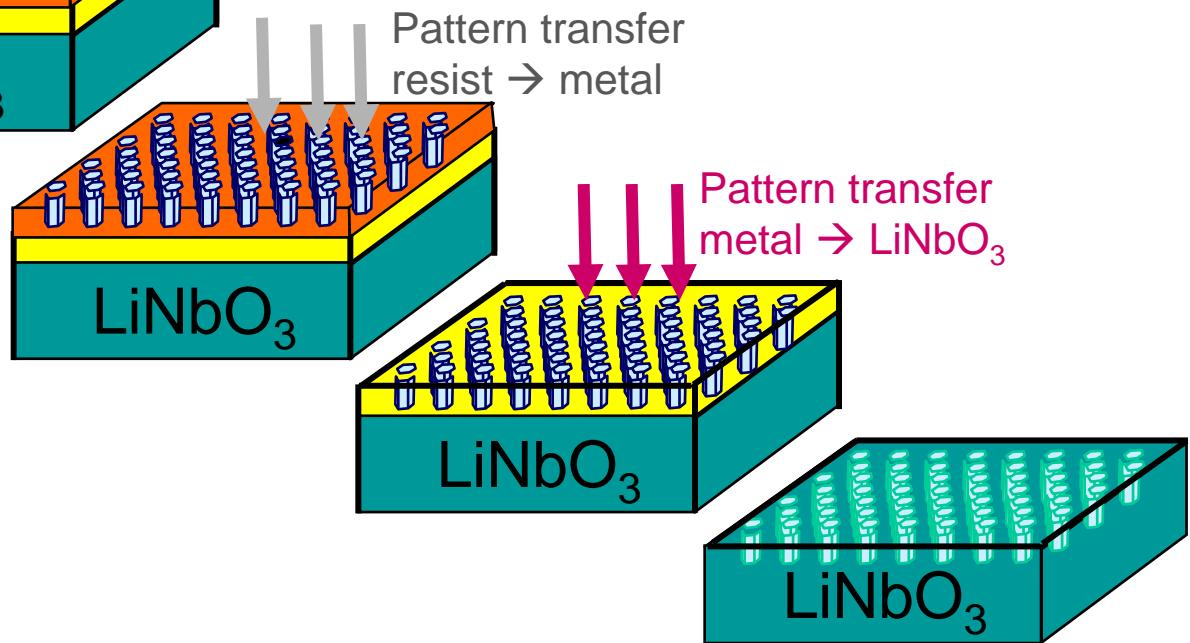


- Charge accumulation in substrate
- Relatively long periodic structures
- Relatively deep LiNbO<sub>3</sub> etch (~ 1 μm)

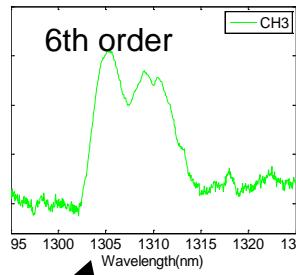


- LiNbO<sub>3</sub> gets charged very easily → use intermediate metal masking layer

- LiNbO<sub>3</sub> etches slowly (~ 50 nm/min in SF<sub>6</sub> RIE) → find conditions for good pattern transfer (mask, RIE, substrate pre-treatment)

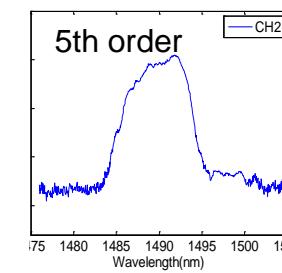
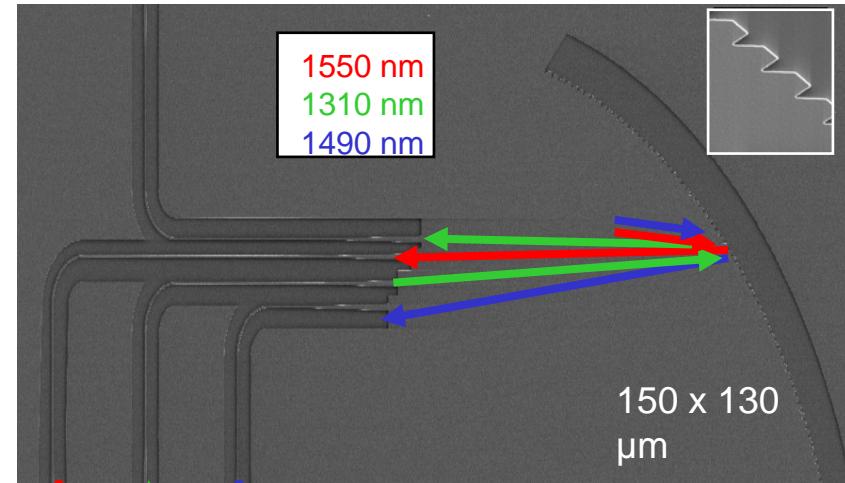
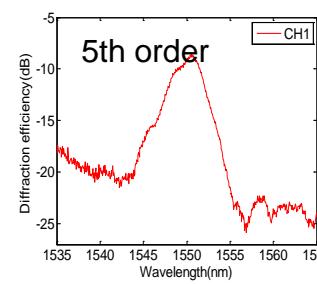


# SOI cross-order Echelle-grating triplexer



*Lech Wosinski, FMI, KTH Kista*

Different diffraction orders to cover large spectral range and keep the device compact.



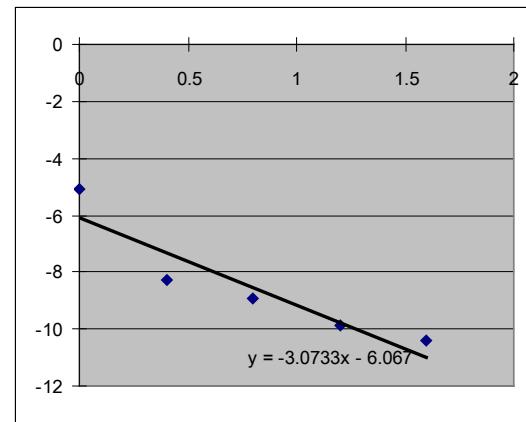
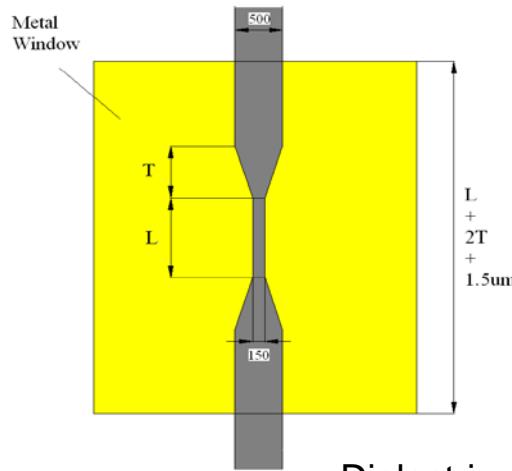
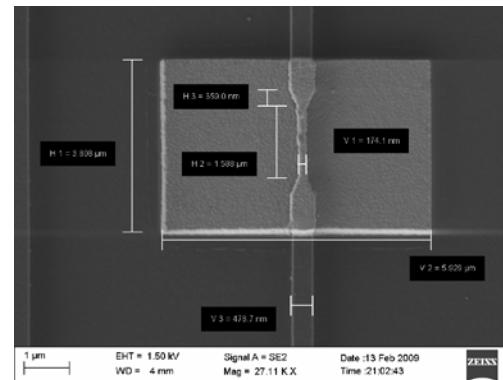
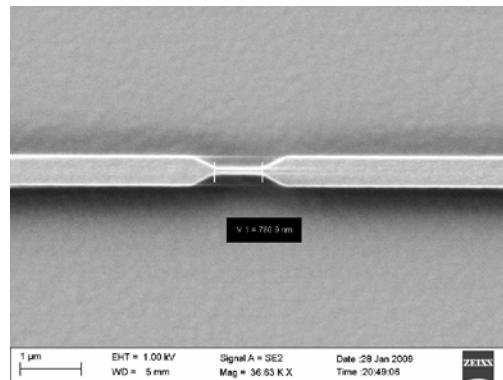
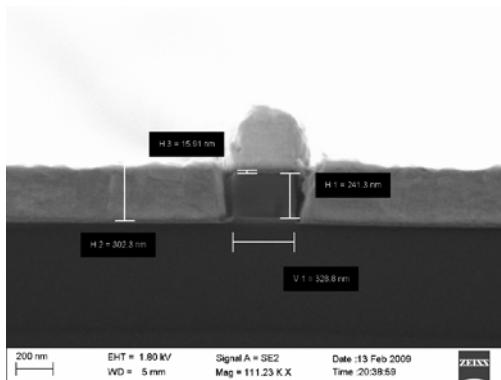
## RESULTS:

- crosstalk < 20dB
- loss per channel  $\approx$  11dB

“Experimental demonstration of a cross-order echelle grating triplexer based on an amorphous silicon nanowire platform”, N. Zhu, J. Song, L. Wosinski, S. He and L. Thylen, Optics Letters, Vol. 34, 383-385 (2009).

# Plasmonic slot waveguides for photonics

*Lech Wosinski, FMI, KTH Kista*



## RESULTS:

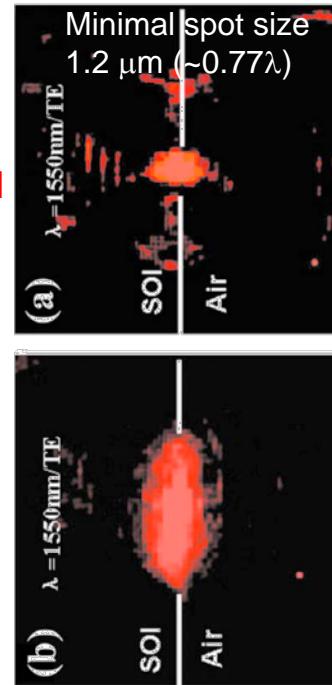
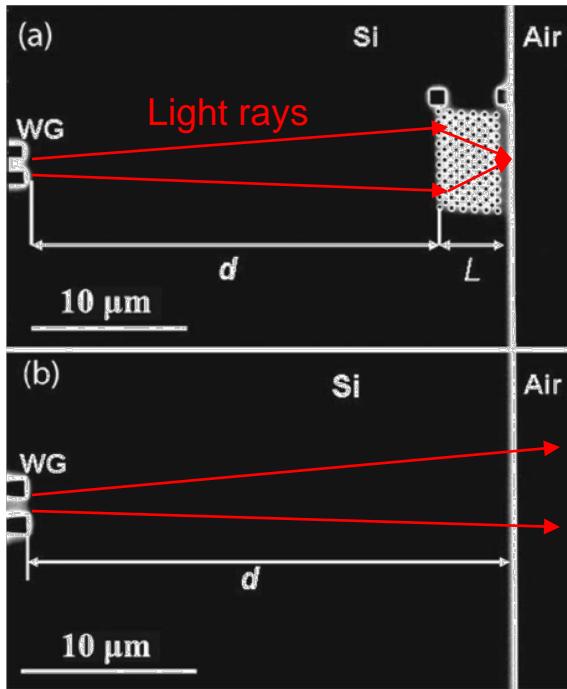
- Propagation loss =  $3.0733 \text{ dB}/\mu\text{m}$
- Loss of coupling between 500nm Si waveguide to 500nm Si wg with metal =  $2.1 \text{ dB/facet}$
- Loss of taper/350nm =  $0.4 \text{ dB/taper}$

Dielectric and plasmonic slot waveguides for photonic integration

B.Jaskorzynska, Y. Song, N. Zhu, Z. Wang, M. Qiu and L. Wosinski , ICTON 2009, Procs of the IEEE.

# Focusing light by negative refraction

Min Qiu, Photonics, KTH

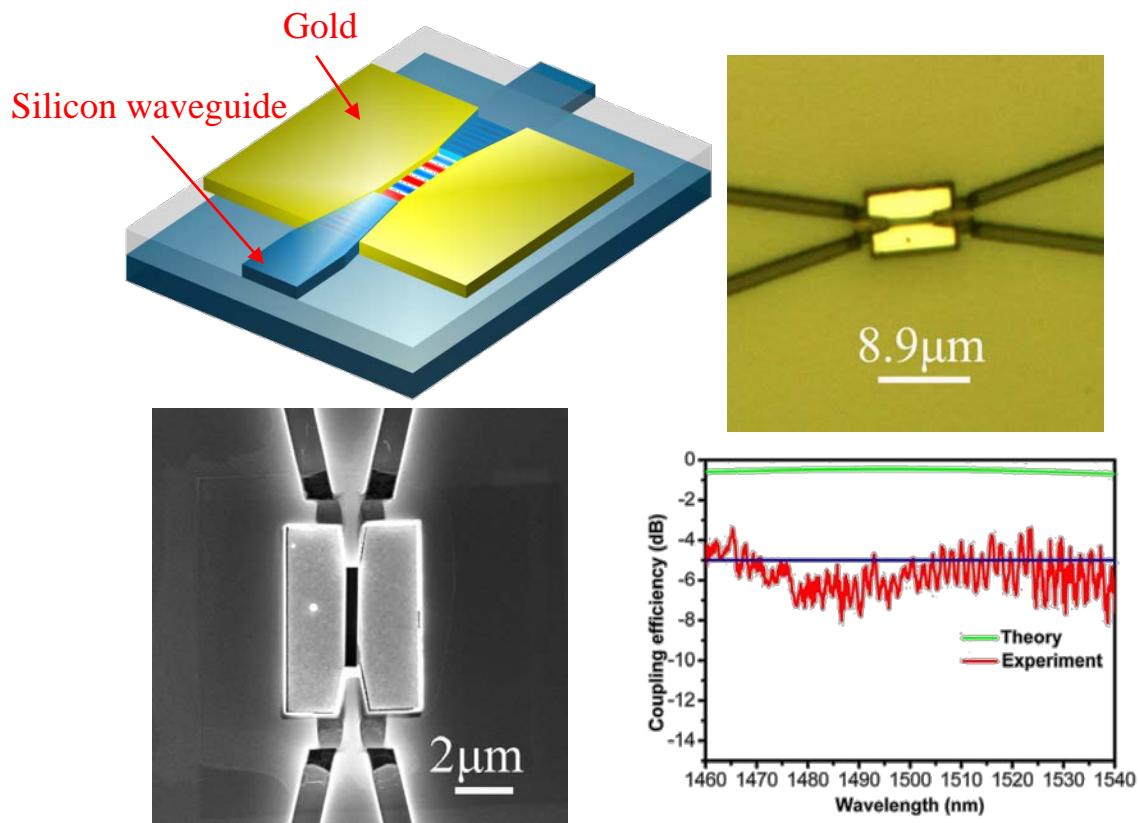


- Near infra-red light focused demonstrated by a two-dimensional silicon photonic crystal flat lens
- Photonic crystal slab fabricated on a silicon-on-insulator substrate by focused-ion-beam direct milling
- Sub-wavelength focusing observed

Direct characterization of focusing light by negative refraction in a photonic crystal flat lens  
J. Tian, M. Yan, M. Qiu, C. G. Ribbing, Y.-Z. Liu, D.-Z. Zhang, and Z.-Y. Li, Appl. Phys. Lett. **93**, 191114 (2008)

# Broadband plasmonic waveguide coupler

*Min Qiu, Photonics, KTH*



- Plasmonic coupler is composed of a tapered silicon strip waveguide and a subwavelength metal gap waveguide
- 35% coupling efficiency per facet demonstrated
- A crucial step for hybrid integration of plasmonic components with conventional dielectric components

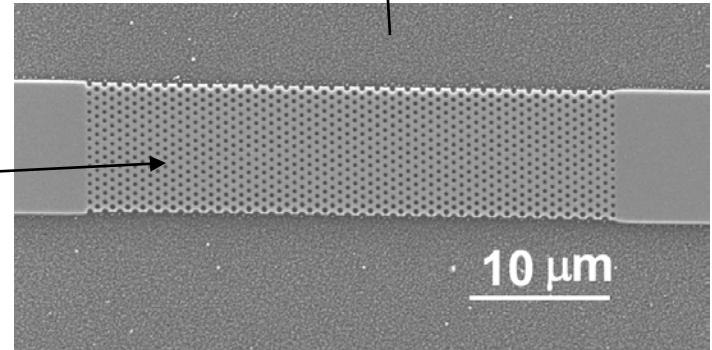
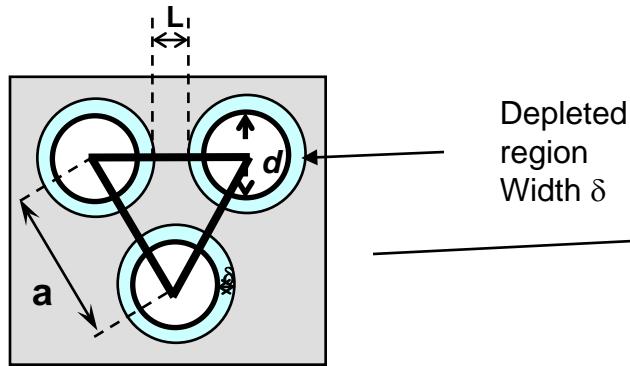
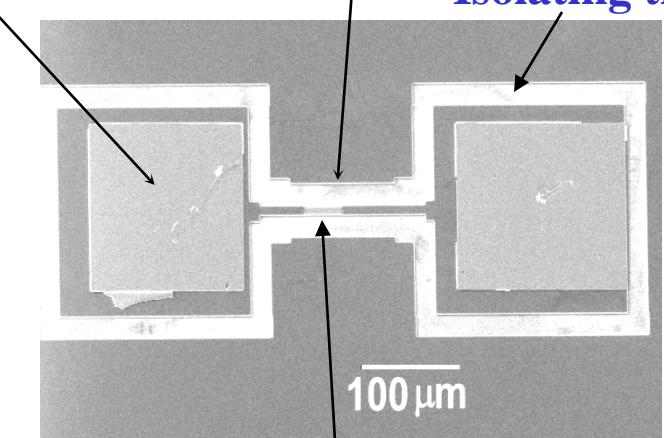
Broadband high-efficiency surface-plasmon-polariton coupler with silicon-metal interface  
J. Tian, S. Yu, W. Yan, and M. Qiu, *Appl. Phys. Lett.* **95**, 013504 (2009)

# Carrier Transport in 2D-Photonic Crystals

*Srinivasan Anand, MAP, KTH Kista*

- InP active material, 2D photonic crystal
- Electrically addressed Photonic crystal devices:
- Electrical contact schemes
- Pattern dependent electrical properties

Contact pad      Conducting channel      Isolating trench

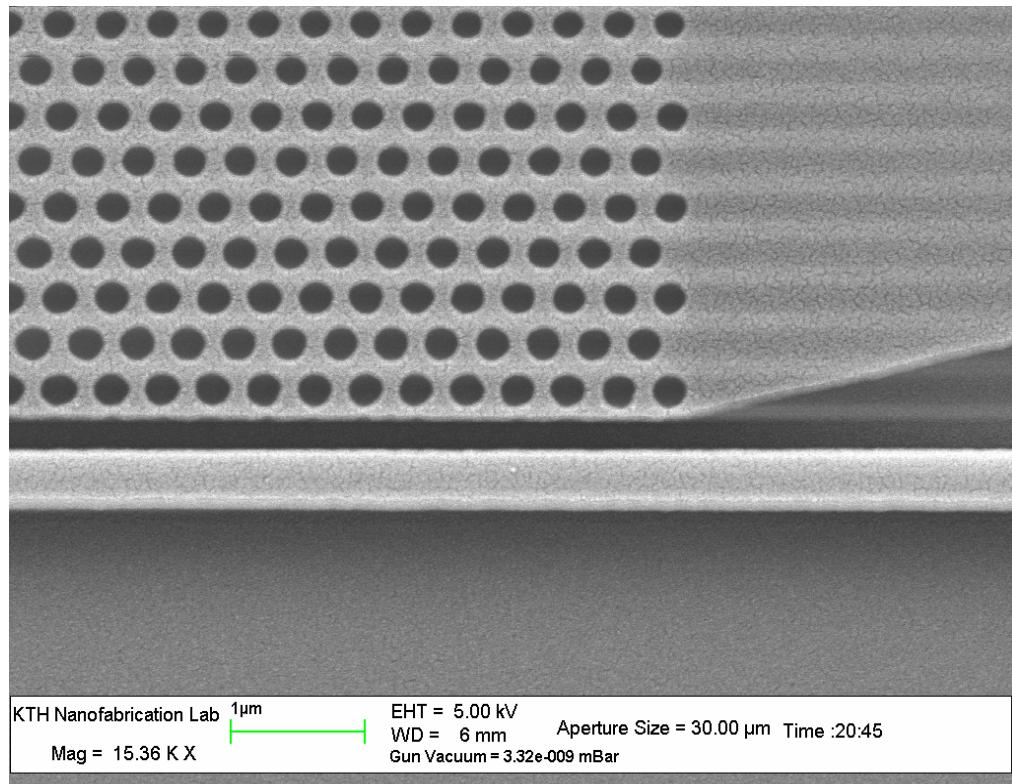
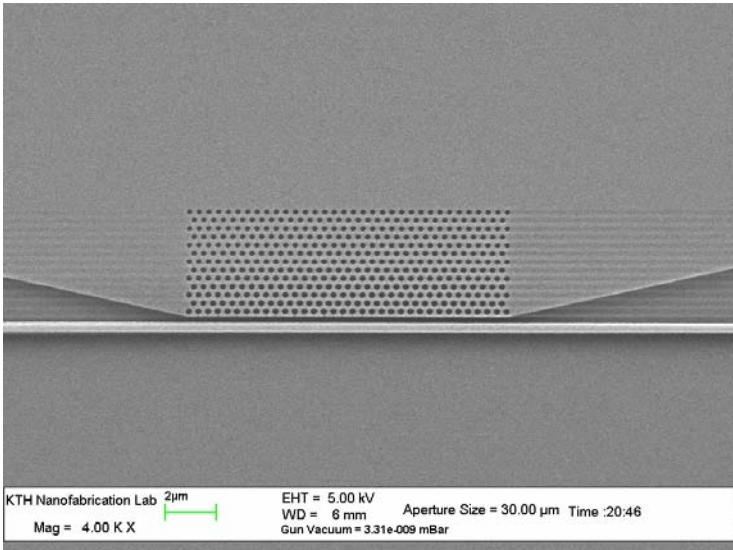


A.Berrier, M. Mulot, G. Malm, M. Östling and S. Anand, Proc. SPIE Optics and Photonics'06

# Surface-mode cavity in 2D photonic crystal slabs

*Min Qiu, MAP, KTH Kista*

- PECVD growth of amorphous silicon on silica structure
- E-beam lithography
- ICP etching
- Application for high Q optical filter

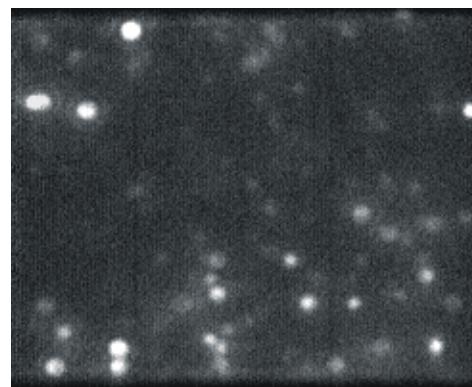
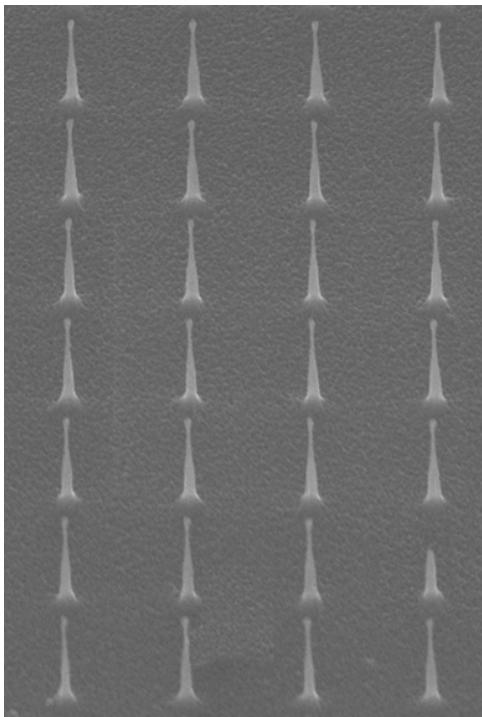


Ziyang Zhang, Matteo Dainese, Lech Wosinski, and Min Qiu, Accepted Appl. Phys. Lett. 2006

# Silicon quantum dots

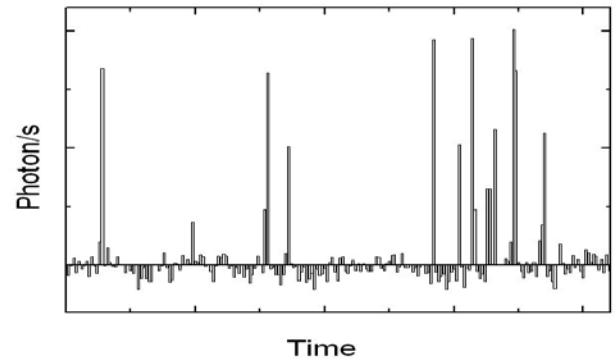
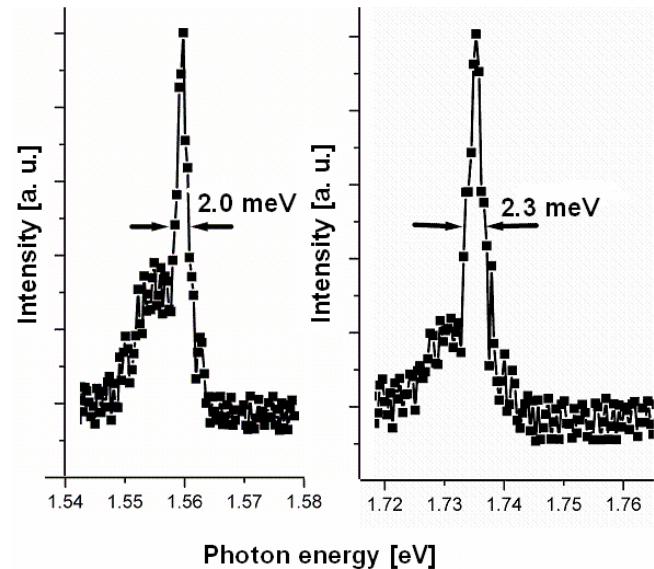
*J. Linnros, MAP, KTH Kista*

- E-beam lithography
- Size reduction by oxidation
- Removal of oxide



Sharp Photo  
Luminescence  
emmision lines

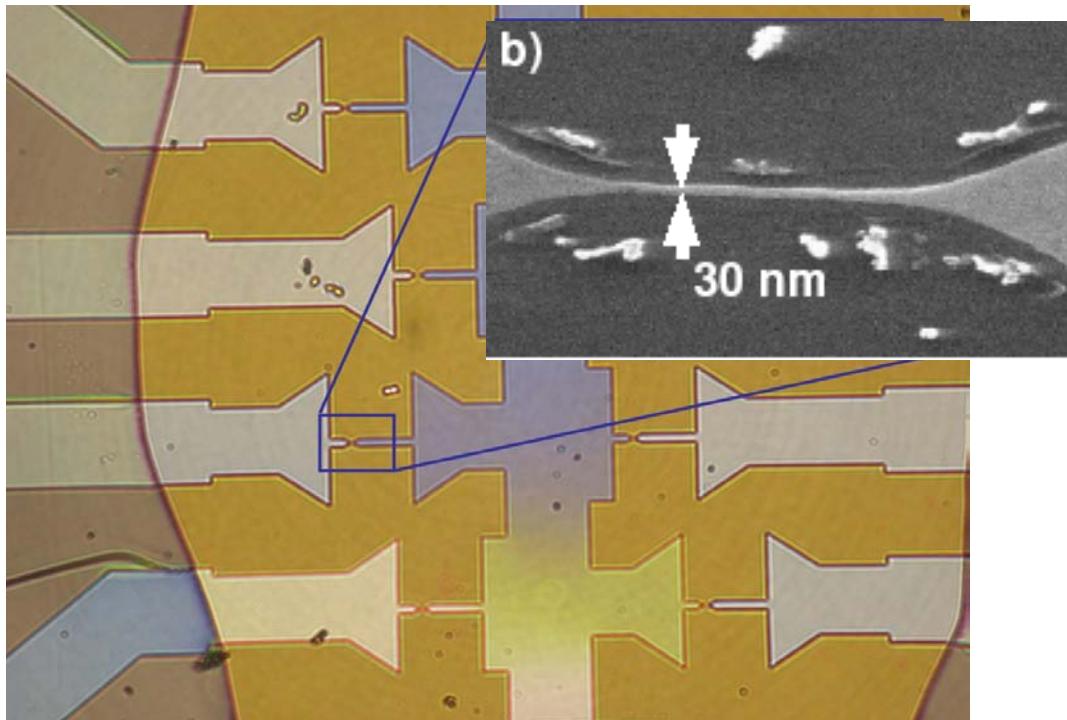
On/Off Blinking



*Sychugov et al. PRL 94, 087405 (2005), Sychugov et al. PRB 71, 115331 (2005)*

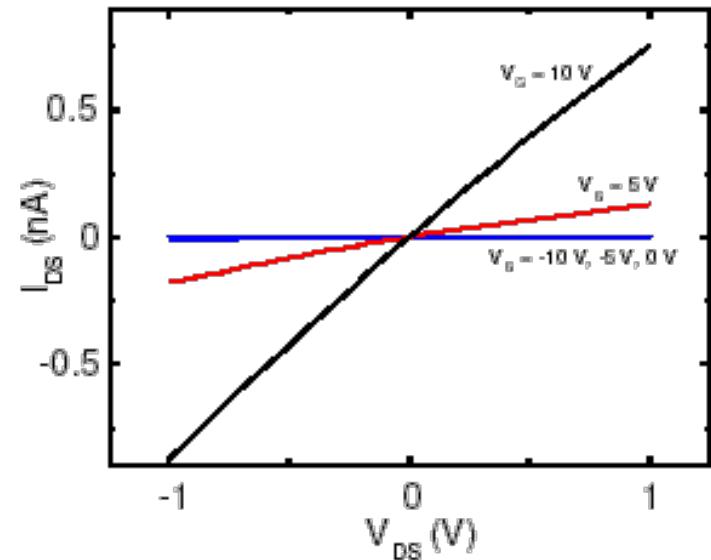
# Silicon nanowires

*J. Linnros, MAP, KTH Kista*



- Chip, SOI technology
- Electron beam lithography
- Size-reduction by
- electrochemical etching

*Juhasz et al., NanoLett 5, 275 (2005)*

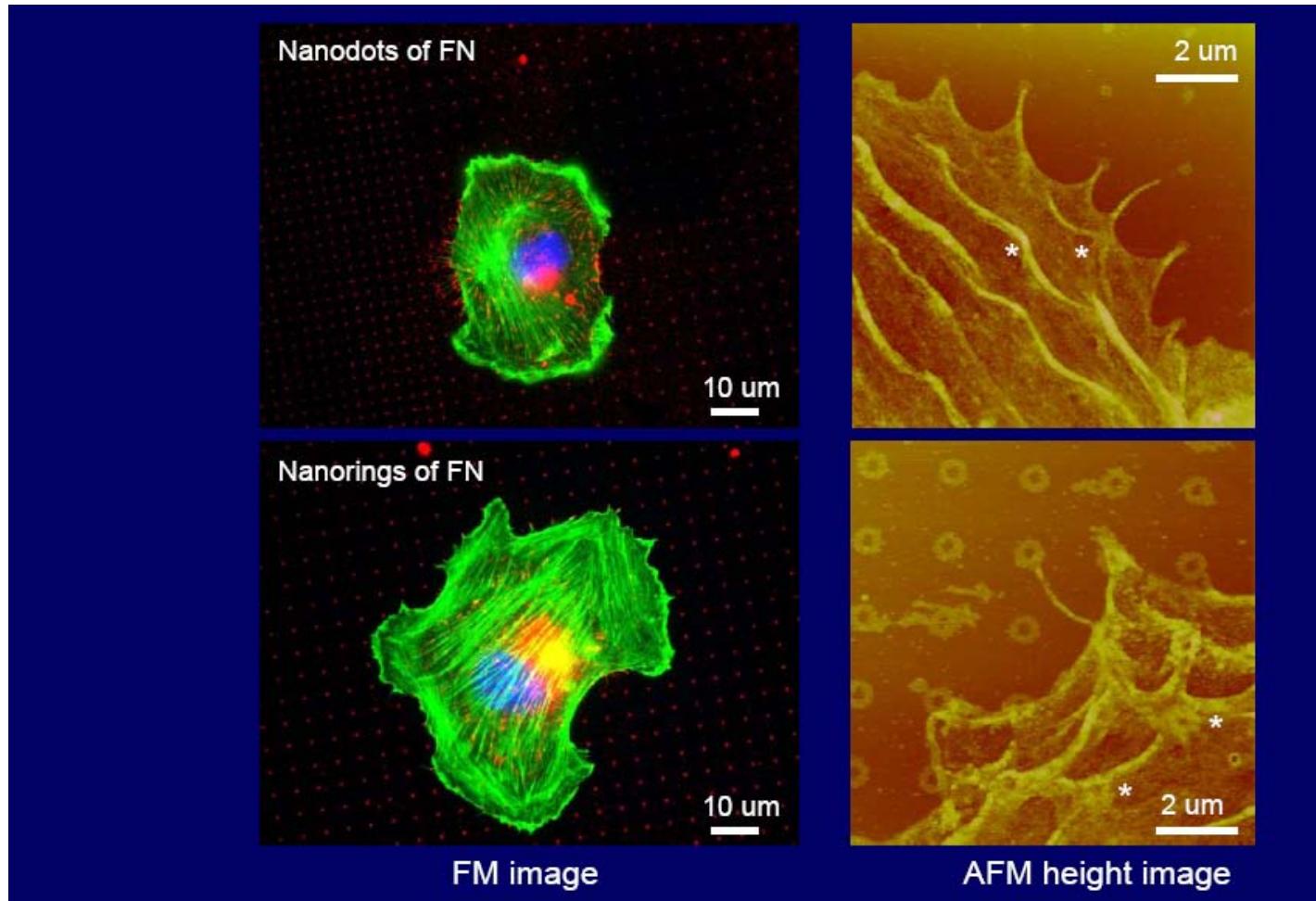


Transistor characteristics



# Nano-Patterned Protein templates for cell growth studies

*David Haviland, Applied Physics, KTH AlbaNova*

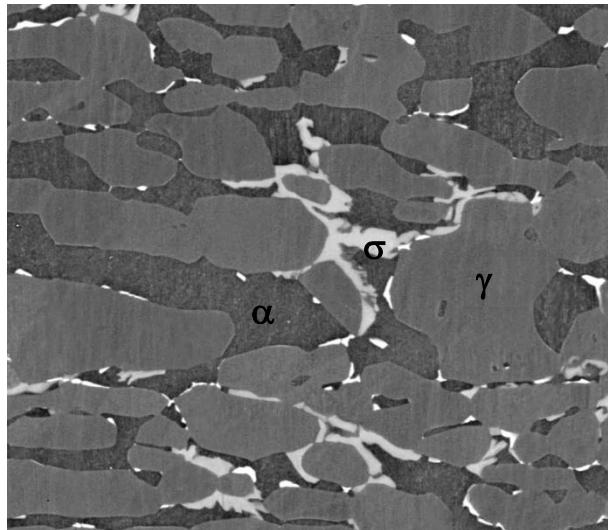


*Modulation of Cell Adhesion Complexes by Surface Protein Patterns, D. Pesen and D. B. Haviland,  
ACS Appl. Mater. Interfaces, 1, 543-548 (2009). (featured article on cover)*

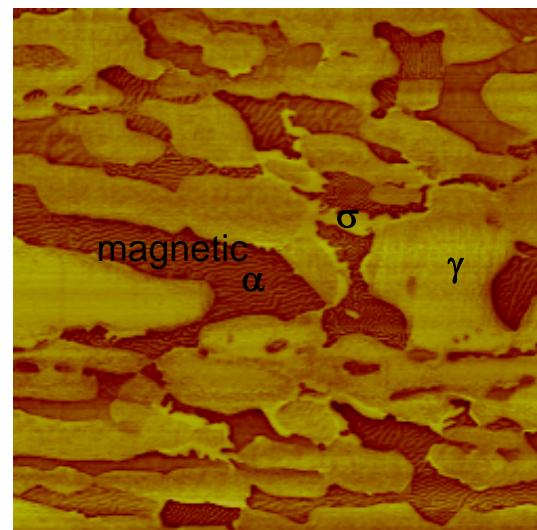
# Characterization of relative nobility of phases in duplex stainless steel

*Jinshan Pan, Surface & Corrosion Science, KTH*

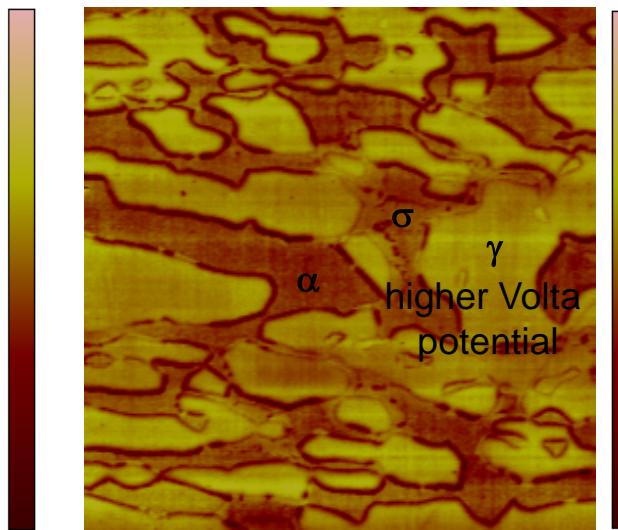
Duplex stainless steel 2205, heat treated, contains ferrite ( $\alpha$ ), austenite ( $\gamma$ ) and sigma ( $\sigma$ ) phases



**BSE-SEM ( $\sigma$  bright phase)**



**MFM ( $\alpha$  magnetic pattern)**

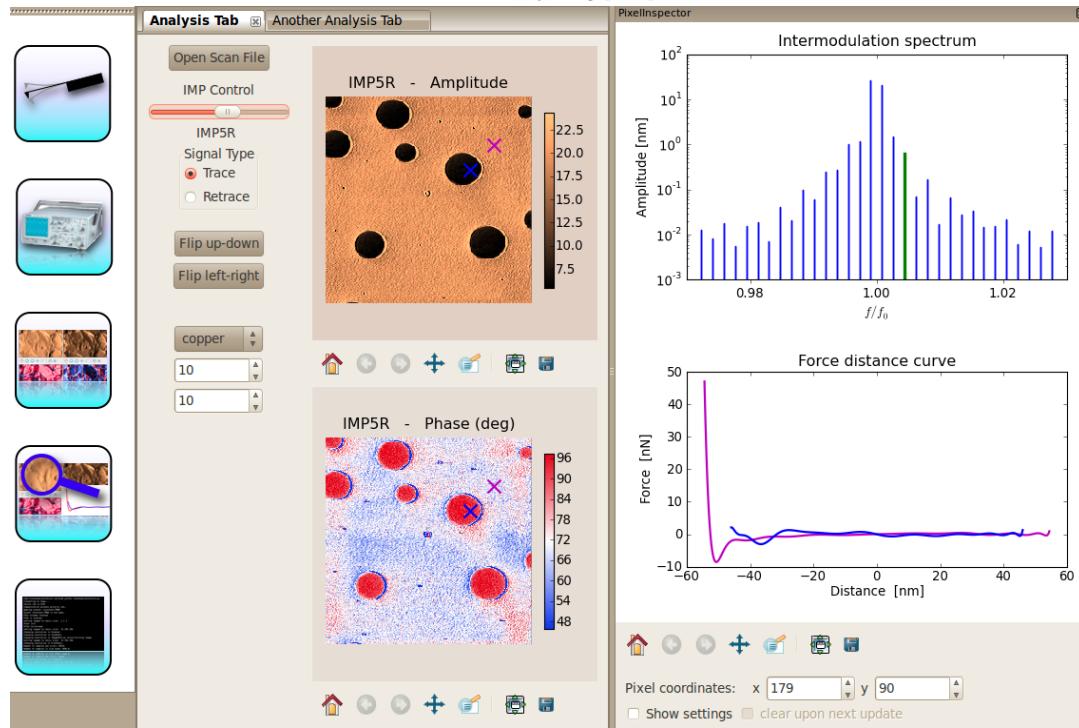
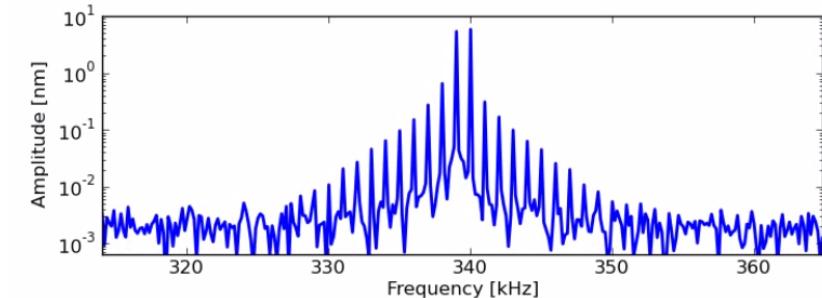
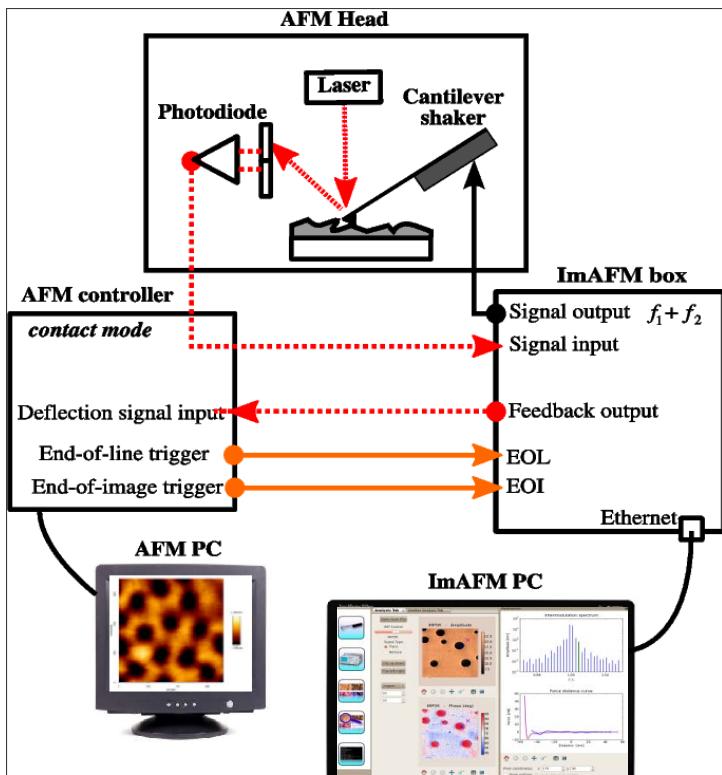


**SKPFM ( $\gamma$  higher Volta potential)**

Characterization of phases in duplex stainless steel by magnetic force microscopy scanning Kelvin probe force microscopy  
N. Sathirachinda, R. Gubner, J. Pan, U. Kivisäkk, *Electrochem. Solid-State Lett.*, **11**, C42-C45 (2008)

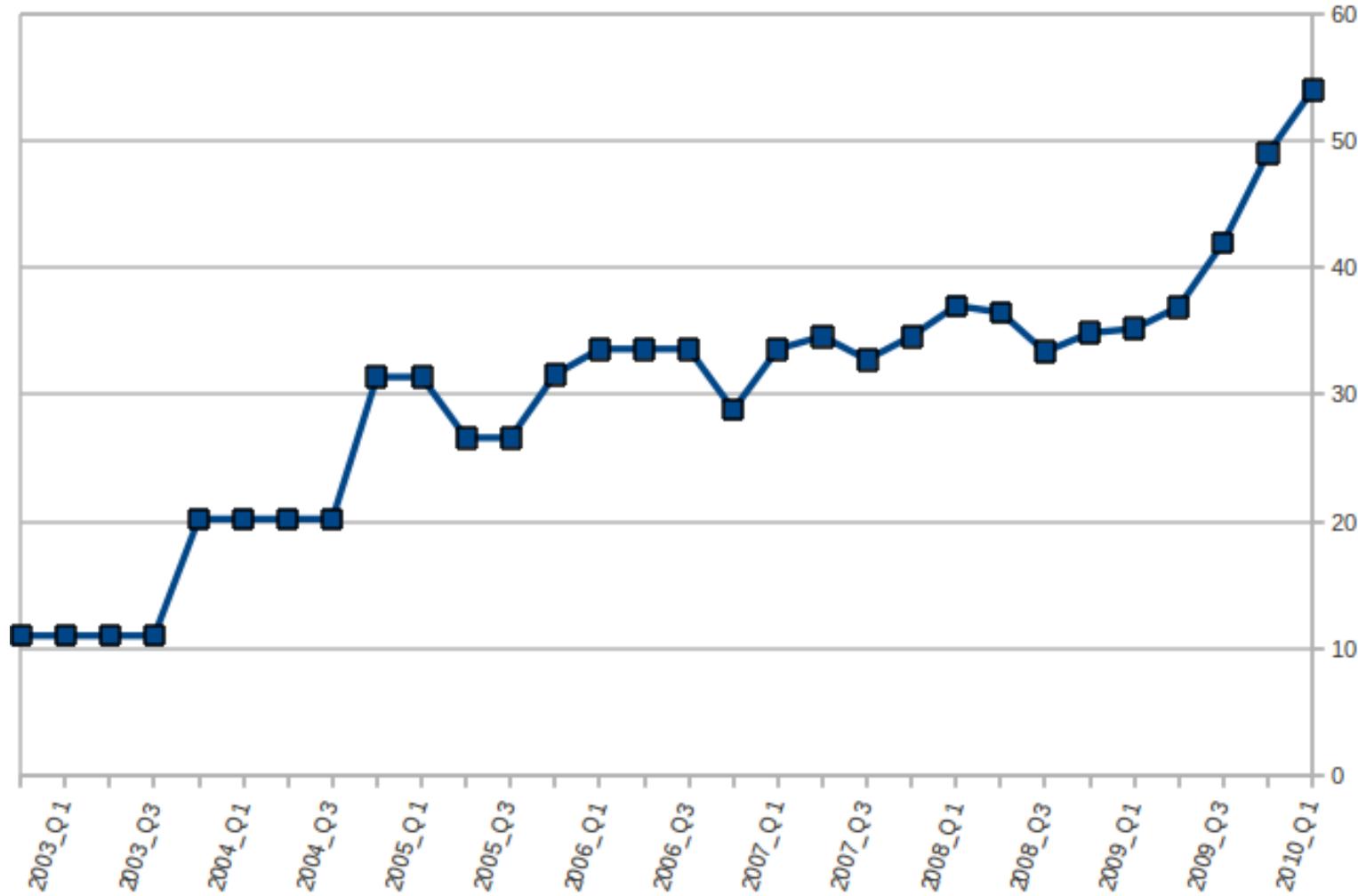
# Intermodulation Atomic Force Microscopy

*David Haviland, Applied Physics, KTH Albanova*



## AlbaNova Nanolab users

number of users paying base fee, by quarter

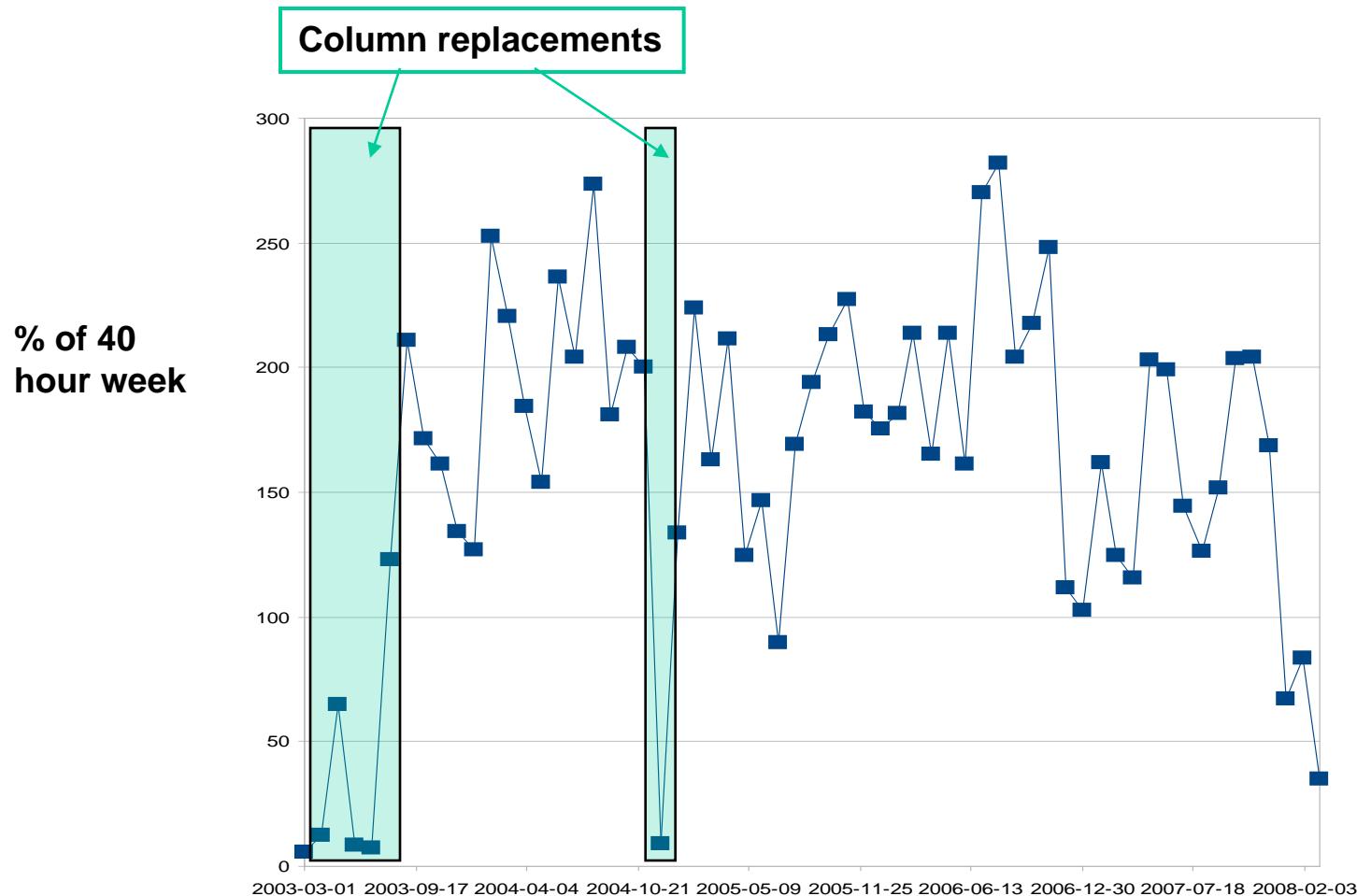


# Productivity as of April 2008

See Appendix 1 of Activity report

- PhD thesis - 21 completed, 24 in progress
- Master thesis - 8
- Post Docs – 6
- Companies - 4

# E-beam usage:



# Low cost, minimal bureaucracy

## 2010 Budget

Total Costs	-3.2 M SEK
Subsidies (KTH Aphys, SU phys)	+1.1 M SEK
User fees	+2.1 M SEK

User fees: 54 paying base fee (2010\_Q2)

- base fee 6250 SEK per user per quarter year
- time charge on e-beam, SEM/FIB, mask align, AFM

Low cost structure because we are slim: 1 FTE technician salary, everyone helps with maintenance, education, weekly user meetings.

# Access Example: E-beam Lithography

- Internal (Inst. pays subsidy)
  - 6250 SEK /quarter base fee
  - 275 SEK/hr machine time
    - $\frac{1}{2}$  price after 6pm, free midnight to 7am
- External (Inst. does not pay subsidy)
  - 6250 SEK/quarter base fee
  - 600 SEK/hr machine time
    - $\frac{1}{2}$  price after 6pm, free midnight to 7am

# Outlook

- Can accommodate 2 systems, ca 10 users with current space
- Need to increase technical staff
- Develop SPM – more users from Chemistry
- Part of Aphys Labs (Laser, Bio-Image, Cell growth)
- Incubator for small companies
  - Xcilium
  - Intermodulation Products